

ELECTRONIC INFORMATION DISCLOSURE STATEMENT

Electronic Version v18

Stylesheet Version v18.0

Title of Invention

RAISED STI PROCESS FOR MULTIPLE GATE OX AND
SIDEWALL PROTECTION ON STRAINED Si/SGOI STRUCTURE
WITH ELEVATED SOURCE/DRAIN

Application Number :

Confirmation Number:

First Named Applicant: Jochen Beintner

Attorney Docket Number: FIS920040005

Art Unit:

Examiner:

Search string: (4881105 or 5801081 or 5858825 or 5874328 or 6184105 or 6197657 or 6248643
or 6333242 or 6350662 or 6358801 or 6583000 or 20010036709 or 20020094649 or
20030119257 or 20030141548).pn

US Patent Documents

Note: Applicant is not required to submit a paper copy of cited US Patent Documents

init	Cite.No.	Patent No.	Date	Patentee	Kind	Class	Subclass
	1	4881105	1989-11-14	Davari et al.			
	2	5801081	1998-09-01	Warashina et al.			
	3	5858825	1999-01-12	Alsmeier et al.			
	4	5874328	1999-02-23	Liu et al.			
	5	6184105	2001-02-06	Liu et al.			
	6	6197657	2001-03-06	Tsukamoto			
	7	6248643	2001-06-19	Hsieh et al.			
	8	6333242	2001-12-25	Hwang et al.			
	9	6350662	2002-02-26	Thei et al.			
	10	6358801	2002-03-19	Fazan et al.			
	11	6583000	2003-06-24	Hsu et al.			

US Published Applications

Note: Applicant is not required to submit a paper copy of cited US Published Applications

init	Cite.No.	Pub. No.	Date	Applicant	Kind	Class	Subclass
	1	20010036709	2001-11-01	Andrews et al.			
	2	20020094649	2002-07-18	Arthanari et al.			
	3	20030119257	2003-06-26	Dong et al.			

	4	20030141548	2003-07-31	Anderson et al.			
--	---	-------------	------------	-----------------	--	--	--

Signature

Examiner Name	Date